
Classification and Key Feature Extraction for Equipment Health Monitoring in Plasma Etching

GMM Fachgruppe 1.2.3. – Abscheide- und Ätzverfahren

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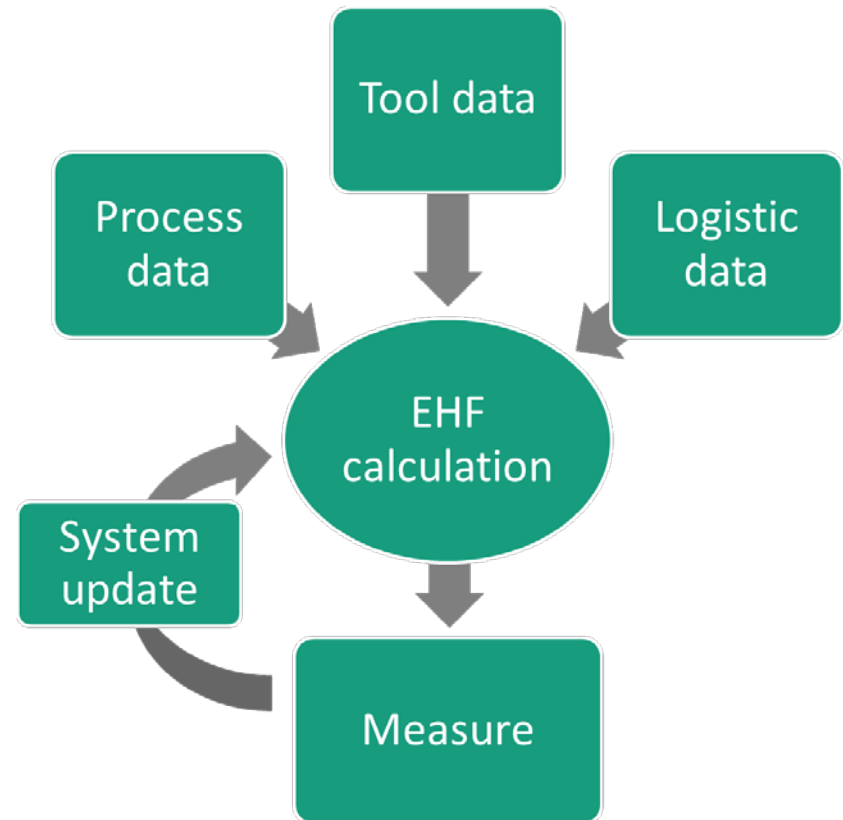
Outline

- I. Motivation
- II. Classification of curve shapes
- III. Key feature extraction
- IV. Application examples
- V. Further steps for EHF calculation
- VI. Conclusion

I. Motivation

Definition: Equipment health factor

- Key indicator for monitoring of equipment state
- Based on process/tool, logistic and metrology data
- Utilization of historical data for training of EHF system
- Related key words
 - Equipment health monitoring
 - Equipment fingerprinting
 - Health index
 - EHF



Goal of the EHF application is to enable...

- **Dynamic Sampling**

Sampling rate is flexible and adjusted to the machine state.

- **Material flow of critical products**

The production of critical products (important customers lots, urgent jobs, etc.) is planned only on machines which have a good system state.

- **Predictive Maintenance (PdM) based on condition monitoring**

The PdM offers cost savings over time-based preventive maintenance, because maintenance actions are performed only when necessary.

Instance for EHF application

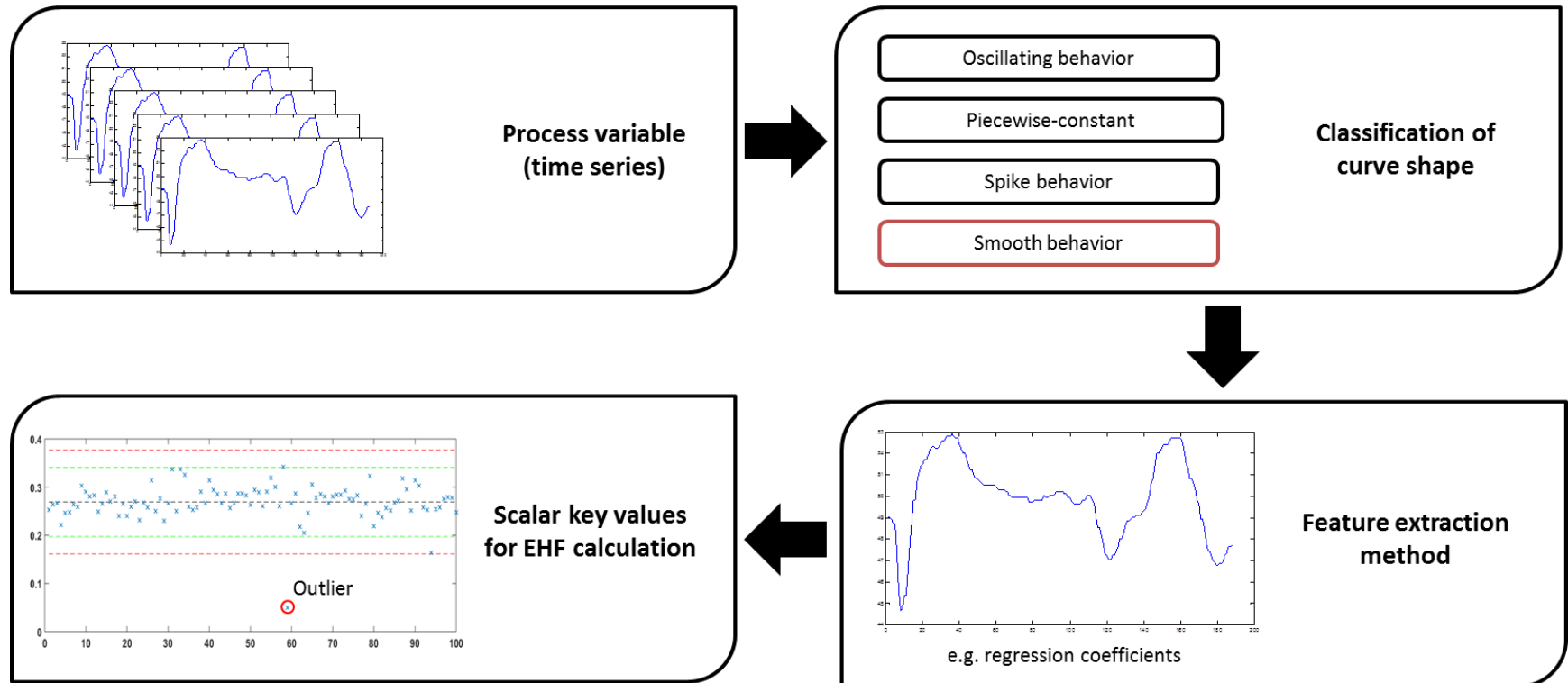
- Good machine state – EHF is high
 - ➔ Lower lot sampling rate, important lots will preferably be scheduled to run on this machine
- Machine state not ideal – EHF decreases
 - ➔ More frequent lot sampling, important lots might be scheduled to run on another tool
- “bad” machine state – EHF drops below certain limit
 - ➔ Schedule maintenance

Related work

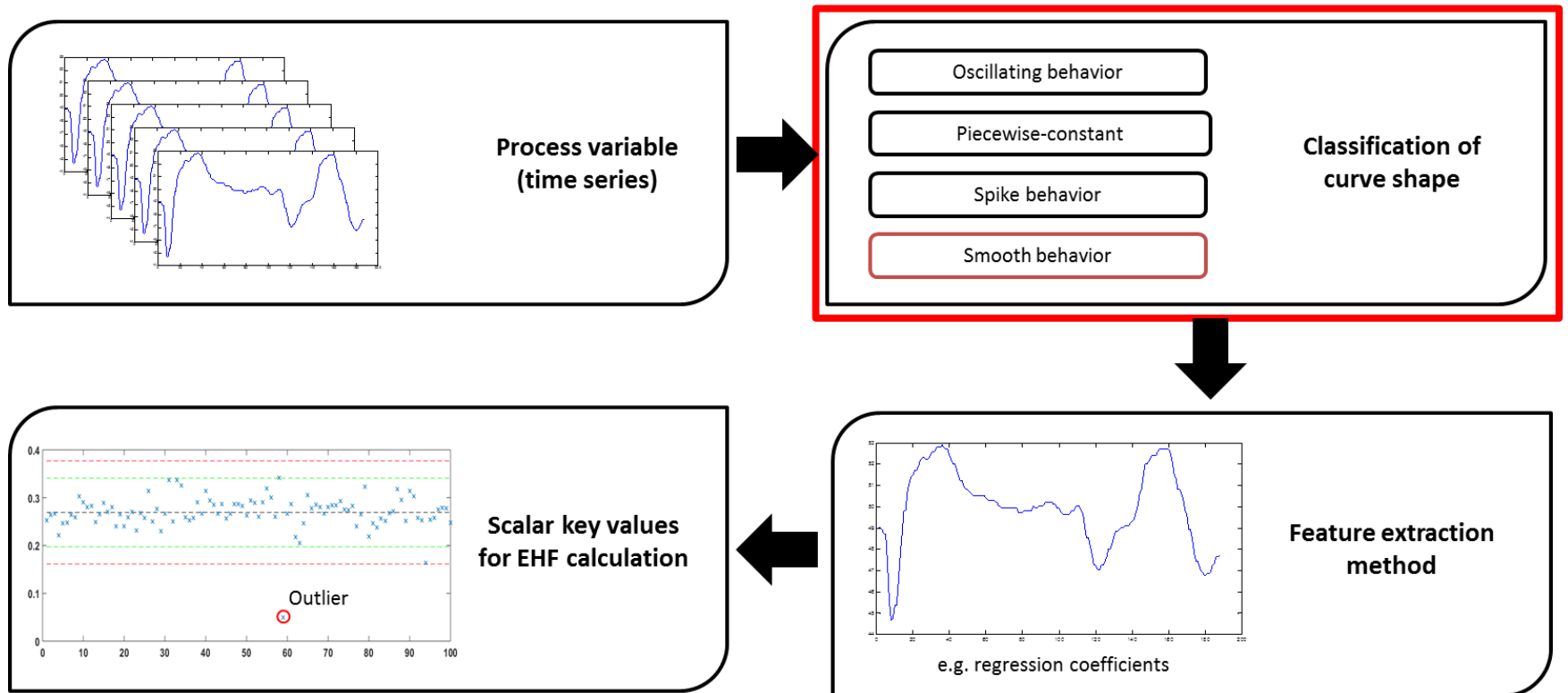
- Utilization of sensors for simple measurement of wear
- Detection of failures based on key indicators
- Usually only implemented for specific failure classes
- No general method for detection of unknown failures

- **Our objective:**
 - Improved preprocessing method to find unknown failures
 - Use of various feature extraction methods dependent on curve shape
 - Generic concept transferable to other processes

Our approach for EHM



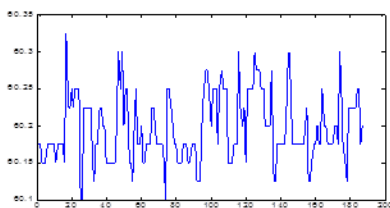
II. Classification



Defined variable types

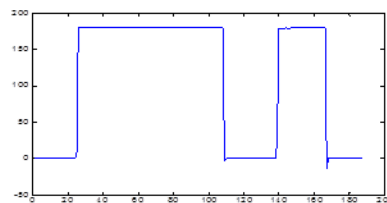
- **Oscillating behavior:** trajectories with periodical variation around a central value
- **Piecewise-constant:** rectangular shaped pulses
- **Spike behavior:** most data points are close to zero with occasional peaks
- **Smooth behavior:** data with little change in their point to point value, the derivation showing only small differences in the gradient

Oscillating behavior



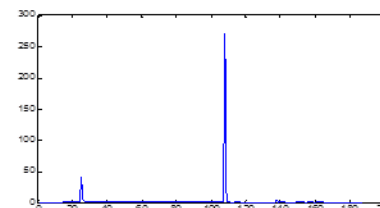
e.g. chamber temperature

Piecewise-constant



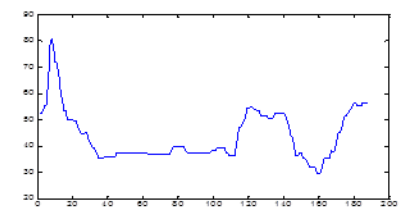
e.g. gas flows

Spike behavior



e.g. reflected RF power

Smooth behavior

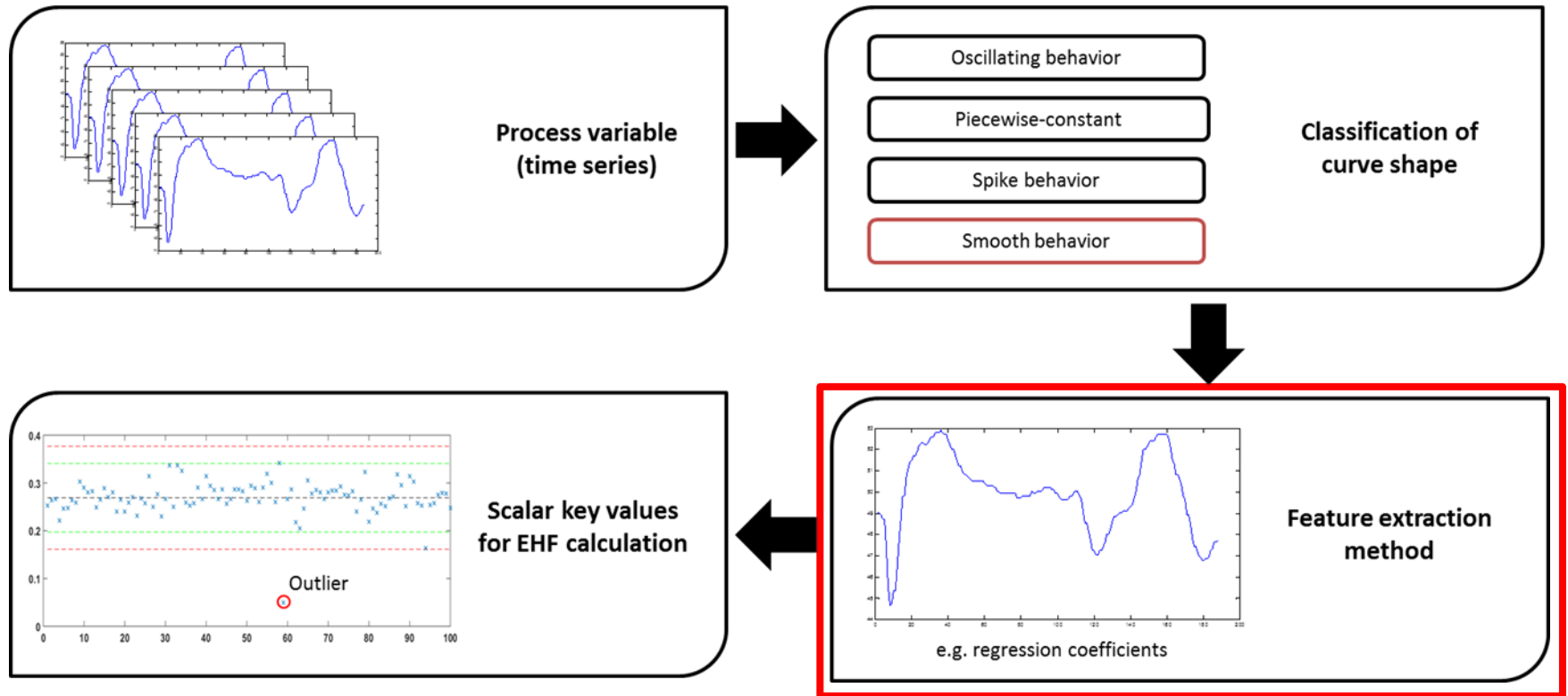


e.g. ESC temperature values

Classification through cubic Support Vector Machine

- Create a training data set containing assignment of variable types
- Cubic support vector machine (SVM) was used
- As predictors were chosen:
 - Kurtosis
 - Crest factor
 - Mean difference of normalized derivation
 - Standard deviation of normalized time series
 - Standard deviation of normalized derivation
 - Logical factor for invariant time series (1 for invariant behavior and 0 for other behavior)

III. Feature Extraction



Types of feature extraction

- **Simple key features**
 - Mean, median, standard deviation and range
- **Structural features**
 - Descriptive statistics of trajectories
- **Dynamic time warping**
 - Euclidean-distance-based similarity measurement technique
- **Frequency and time-frequency analysis**
 - Analysis in frequency domain instead time domain
- **Statistical analytical methods**
 - e.g. regression coefficients or residual analysis

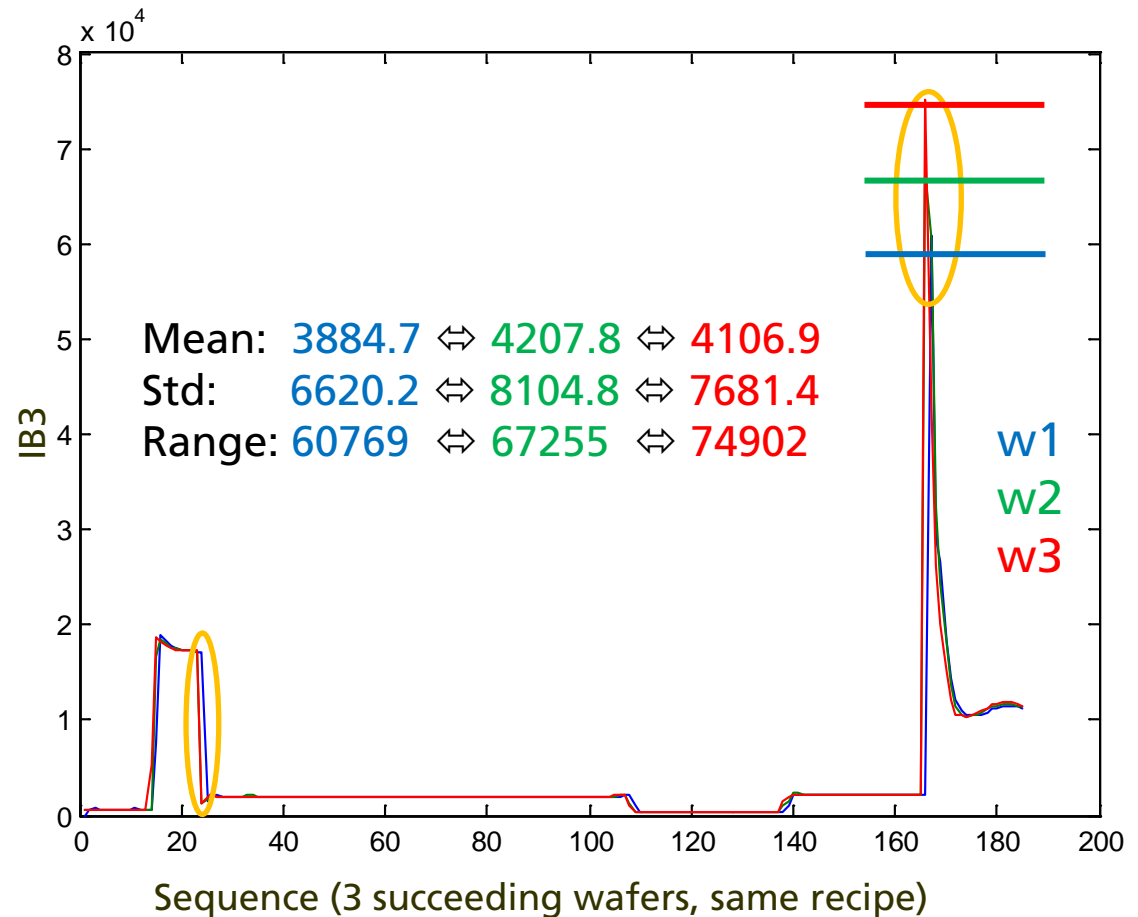
Issues with preprocessing using simple key features

- Over-/undershooting controllers and length of a signal can have big impact on simple key values
- Potential impact of limited data sampling frequency on true transient behavior
- Measurements from etch processes are non-stationary due to:
 - Aging of the etcher after cleaning cycles as residue accumulates on the inside of the chamber
 - Difference in the incoming materials due to changes in upstream processes
 - Drift in process-monitoring sensors themselves

Example for simple key features

Correlation matrix:

	w1	w2	w3
w1	1	-	-
w2	0.7871	1	-
w3	0.6831	0.9802	1



Potential feature extraction methods

Oscillating behavior

- Frequency analysis
- Time-frequency analysis
- Coefficients from time series modeling

Piecewise-constant

- Structural features
- Integration
- Regression coefficients

Spike behavior

- Peak detection
- Structural features
- Integral value of peak

Smooth behavior

- Regression coefficients
- Residual analysis
- Coefficients from time series modeling

Extracted features

Oscillating behavior

- Periodicity
- Trend
- Simple key features

Piecewise-constant

- Number of pulses
- Amount of Under-/Overshoots
- Maximum Overshoot
- Surface area of pulse

Spike behavior

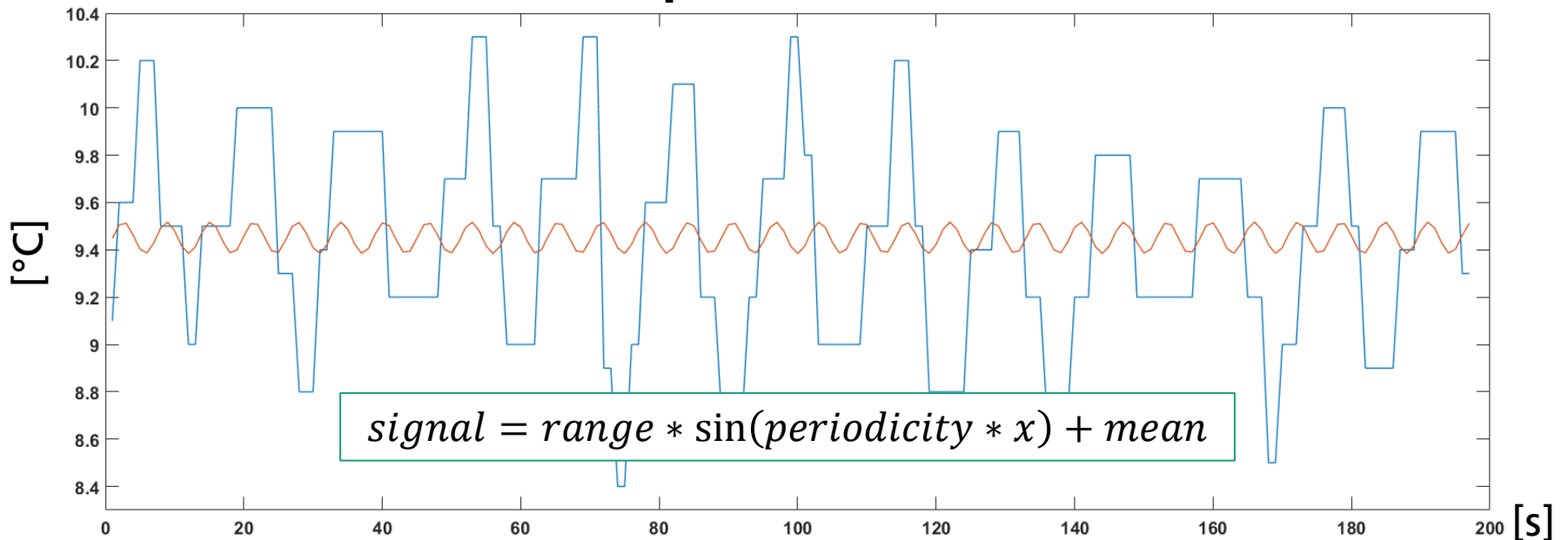
- Number of peaks
- Peak width
- Surface area of peak
- Distance of peaks

Smooth behavior

- Wavelet-based correlation coefficient
- RMS of residuals
- Surface area

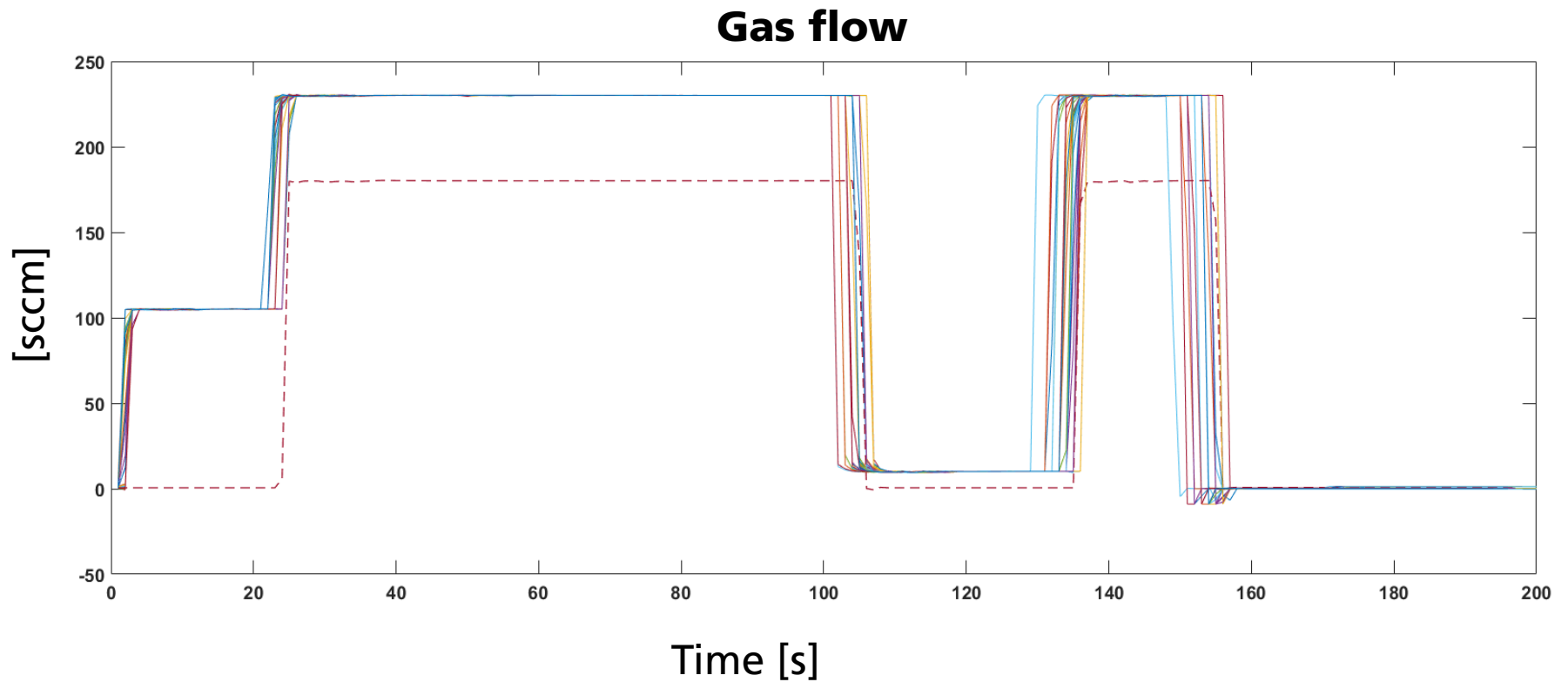
IV. Application example 1

Temperature chiller



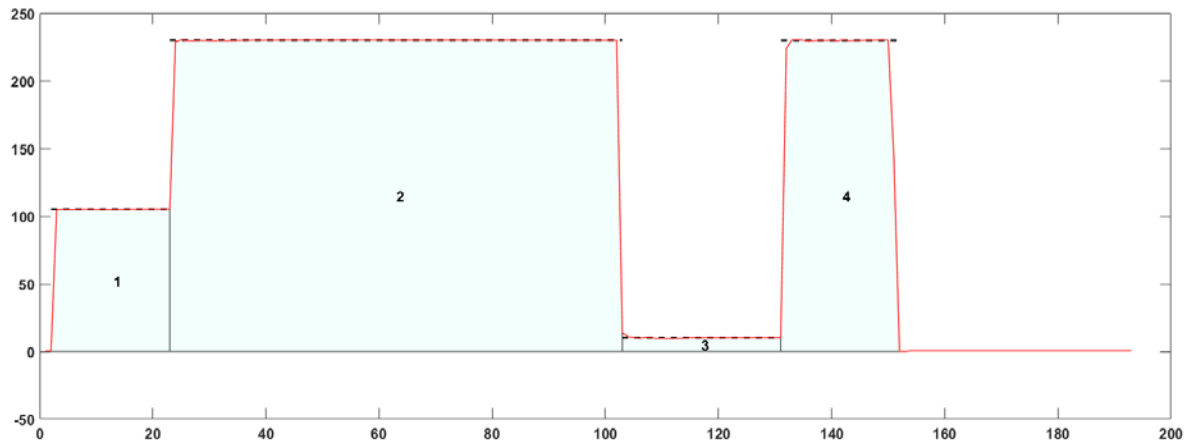
Curve	Mean	Periodicity	Range
Blue	9.4508	15.4763	1.9
Orange	9.4511	6.2733	0.1329

IV. Application example 2 (1/3)

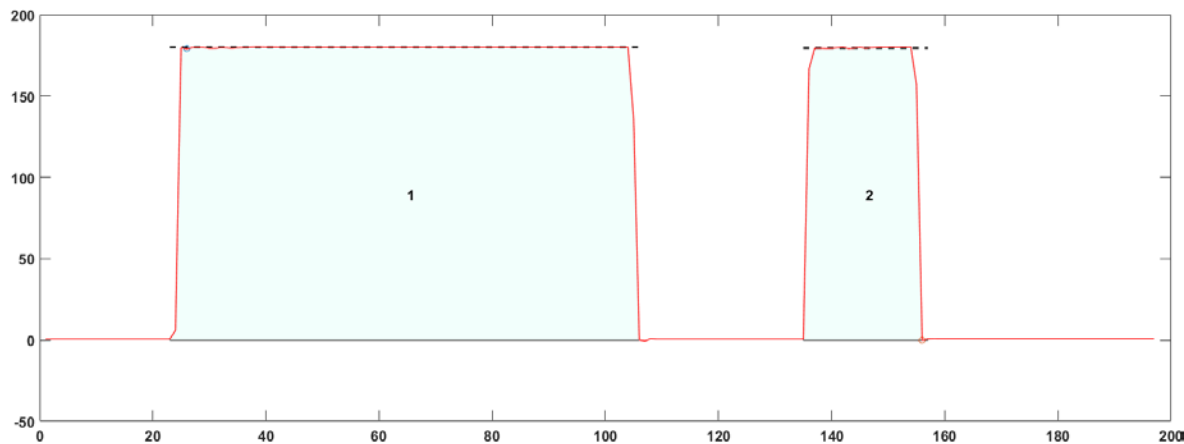


IV. Application example 2 (2/3)

Comparison of two gas flows



Desired trajectory

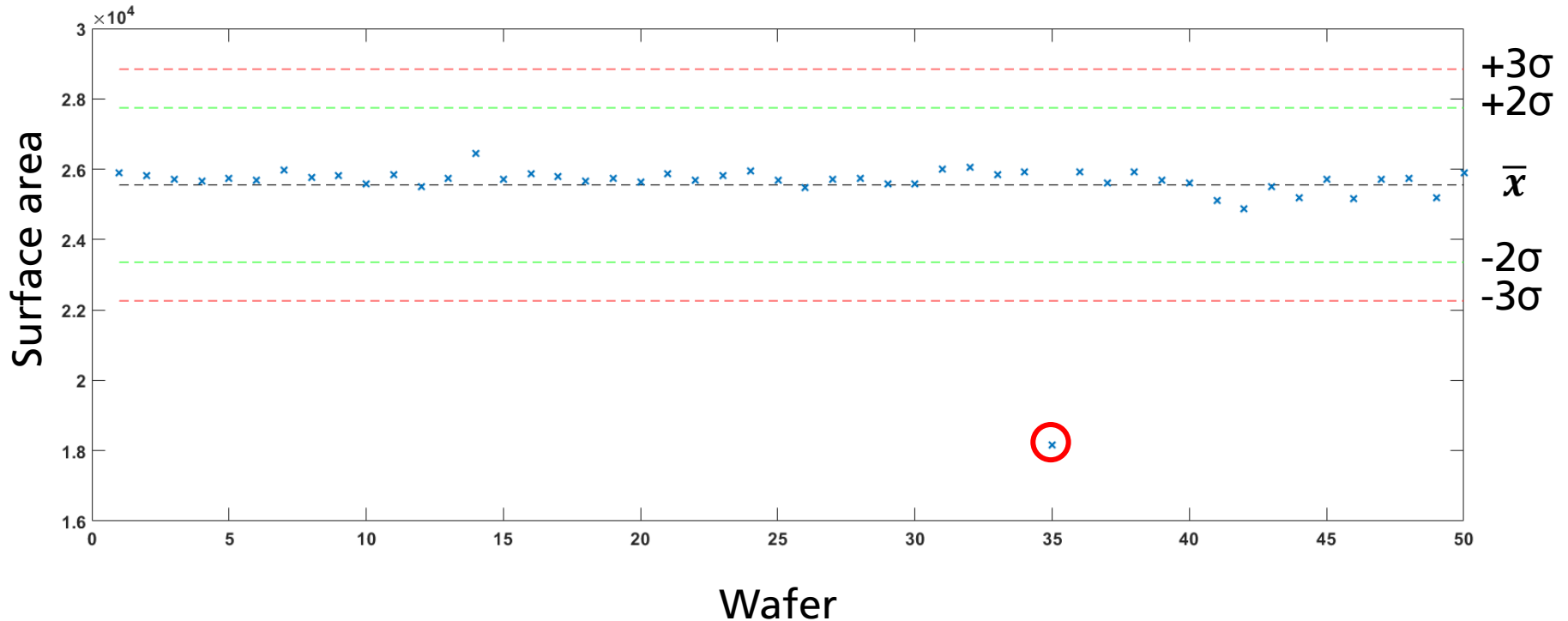


Faulty trajectory

IV. Application example 2 (3/3)

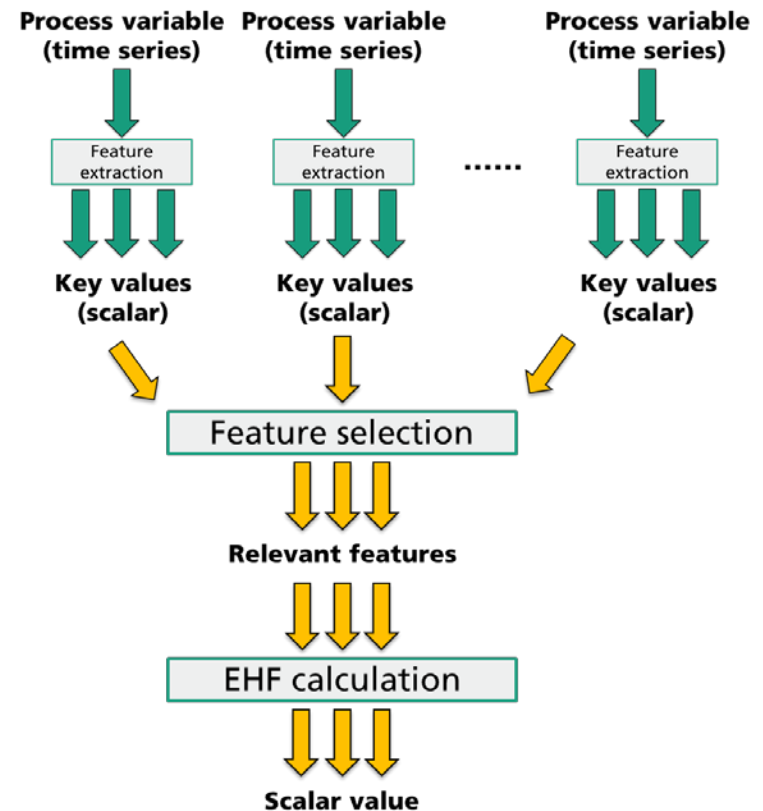
SPC-Chart: Surface Area

× Key feature values ○ Outlier



V. Further steps for EHF calculation

- Feature selection
 - Which features are important for EHF?
 - How to select them automatically?
- EHF Calculation
 - How to combine the relevant key features to a scalar value to express the system state?



VI. Conclusion

- A general method for detection of unknown failures was developed
- Generic concept transferable to other processes
- Application of various feature extraction methods dependent on curve shape
- Extracted key features can be used for EHF calculation or other technologies to improve models, e.g. PCA
- Desired benefit of EHF
 - Lower production costs
 - To support Predictive Maintenance
 - Maintaining high yield

Acknowledgment

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Thank you for listening!